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Influence of structure–property relationships of two structural isomers of thiophene-flanked diazaisoindigo on carrier-transport properties†

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Based on the electron-accepting building block of 7,7'-diazaisoindigo (DAII), two structural isomers of thiophene-flanked diazaisoindigo, 6,6'-substituted 6,6'-T-DAII for full conjugation and 5,5'-substituted 5,5'-T-DAII for cross-conjugation, have been designed and synthesized to study the influence of the connecting positions of the flanking thiophene on the optoelectronic properties, crystal structures, and solid-state microstructures, being well associated with the carrier-transport properties. The results indicate that the 5,5'-substitution on the DAII core of 5,5'-T-DAII stabilizes both the HOMO and LUMO levels and reduces the oscillation strength of the low-energy absorption band as compared to the 6,6'-substitution. In the crystals, 6,6'-T-DAII, 5,5'-T-DAII, and 6,6'-dibromo-DAII adopt a flat platform with co-facial slipped π - π stacking. The organic field-effect transistors based on 6,6'-T-DAII and 5,5'-T-DAII on a tetratetracontane (TTC) modified substrate exhibit an n-dominant ambipolar performance with the hole and electron mobilities of $10^{-3} \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$. Of particular note is that 5,5'-T-DAII show obviously higher carrier-mobilities compared to 6,6'-T-DAII, suggesting that the cross-conjugation of the 5,5'-connection on the DAII core could be designed to improve the carrier-transport properties for FET applications.

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Introduction

Organic semiconductors with the advantages of low cost, large-area printing, mechanical flexibility, and tunable electronic structures are of particular interest for the development of organic field-effect transistors (OFETs).^{1–6} Donor–acceptor (D–A) alternation of π -conjugated semiconductors is commonly used to tune the optoelectronic properties and tighten the intermolecular packing coming from the electron push–pull effect between the donor and acceptor parts, and thereby improve the OFET performance with mobilities over $10 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ for holes^{7–9} and $6 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ for electrons.^{10,11} Compared to the hole-transporting donor units, the development of the electron-transporting acceptor counterparts is still lagging. Therefore,

one of the main challenges is to design and synthesize new electron accepting units to create both small-molecule and polymer semiconductors. Tailoring the energy of the frontier molecular orbitals (FMOs) using electron-deficient moieties to stabilize the LUMO will eventually lead to conjugated systems favouring n-type carrier-transport.¹² The representative n-type units composed of electron withdrawing amide/imide structures widely reported to date are arylene diimide (naphthalenediimide (NDI) and perylenediimide (PDI)),^{13–15} diketopyrrolopyrrole (DPP),^{15–17} tyrian purple,¹⁸ and isoindigo (IID).^{19–21}

IID is a useful building block for organic electronics due to the electron-deficient character constituting the donor–acceptor (D–A) π -conjugated organic semiconductors that show an excellent performance in organic field effect transistors (FETs) and organic photovoltaics (OPVs) (Fig. 1).²² Based on IID, a practical approach to efficiently create a stronger n-type building block than IID is to afford an electron-negativity on the IID core for realizing a low-lying LOMO level. Moreover, for the chemical modification of IID, the connection modes of the substituents, the 6,6'-substitution for full-conjugation and the 5,5'-substitution for cross-conjugation, remarkably alter its structure–property relation to realize a coplanar and rigid backbone as described in previous reports.^{23–25} When considering the connection patterns of isoindigo to construct small-molecule and polymer semiconductors, the outer benzene ring sometimes forms torsion angles with the connecting

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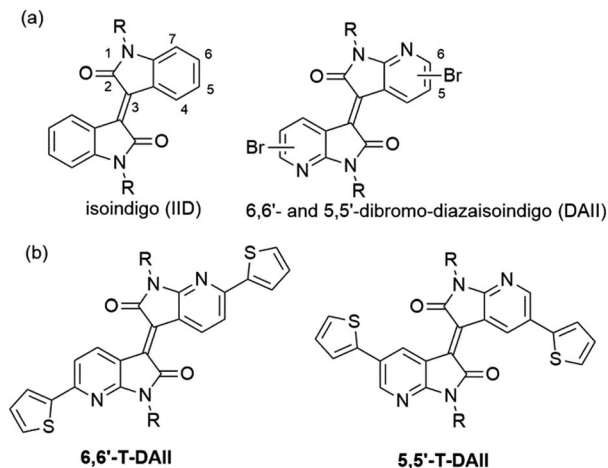


Fig. 1 (a) Chemical structures of isoidindigo and 6,6'- and 5,5'-dibromo-7,7'-diazaisoidindigos and (b) 6,6'-T-DAII and 5,5'-T-DAII.

counterparts, providing the twisted π -conjugated structure, thereby, chemical modifications of the outer benzene ring strongly influence their molecular conformation and electronic structures.^{26–32}

In this context, we have designed two structural isomers of the 6,6'- and 5,5'-dibromo-7,7'-diazaisoidindigo (DAII) as versatile synthetic precursors for the n-type building blocks, wherein the carbons at the 7,7'-positions on the IID core are replaced with electron-negative nitrogens (Fig. 1). These molecules are expected to couple with various counterparts constituting the D–A alternation. We reported, recently, ambipolar organic transistor performance based on IID derivatives including DAII molecules.³³ The introduction of electron-negative nitrogens contributes to lowering the LUMO level. Additionally, the position of the nitrogen substitution on IID proves to be intriguing for the planarization of IID, in which the nitrogen replaced at the 7-position on DAII forms a fully flat molecular geometry estimated from the theoretical calculations.^{34,35} The basic characters of 7,7'-DAII, which have been rarely examined, show a promising building unit for organic electronics.³⁶ Most recently, 7,7'-DAII-based polymers using the 6,6'-D–A alternation exhibit an excellent ambipolar or p-channel FET performance, wherein the hole mobility is over $7 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$.³⁵ For the further advance of DAII-based materials, as well as the electron-deficient character of the DAII unit, the substitution positions should be important to modulate the molecular geometries and electronic structures, enabling a tailored structural design for the device application.

In order to simply interpret the influence of the basic properties of the DAII-based molecules coming from the connection patterns on the carrier-transport properties, we report the design and synthesis of two model molecules of the thiophene-flanked diazaisoidindigos, 6,6'-T-DAII and 5,5'-T-DAII, since the electron-rich thiophene is more popular in designing D–A alternating molecules. Additionally, compared to the conventional 6,6'-connection, exploring the not commonly studied 5,5'-connection is instructive. 6,6'-T-DAII and 5,5'-T-DAII were

fully characterized by X-ray structure analyses, optical spectroscopy, and cyclic voltammetry. Thin-film transistors made of 6,6'-T-DAII and 5,5'-T-DAII exhibited an n-dominant ambipolar behavior irrespective of the connection modes (both the hole-mobilities and electron mobilities are around $10^{-3} \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$) on the tetratetracontane self-assembled monolayers under vacuum conditions. Most importantly, 5,5'-T-DAII exhibits a higher carrier-transport property than 6,6'-T-DAII. The obtained results provide a guideline for designing novel 5,5'-substituted DAII-based small-molecule and polymer semiconductors for FET applications.

Results and discussion

Theoretical estimation

We initially carried out DFT calculations at the ω B97XD/6-31G(d,p) level to estimate the impact on the optimized structures by replacing two carbon positions with the corresponding nitrogens on the IID core (Fig. S1†).³⁴ Of particular note is that the 7,7'-replacement renders the IID core with an entirely flat geometry as compared to other replacements, which agrees with the results of a recent report.³⁵ This observation is presumably due to reducing the electrostatic repulsions with the enlarged distance between the electron-negative nitrogen and oxygen. To evaluate the influence of the connection patterns of the thiophene-flanked 6,6'-T-DAII and 5,5'-T-DAII on the optimized and electronic structures, we calculated four sets of molecules including the IID-based molecules of 6,6'-T-IID and 5,5'-T-IID for comparison (Fig. 2). For ease of the calculations, the hexyl chains were replaced with methyl groups. 6,6'-T-DAII have an entirely flat platform without any noticeable dihedral angles, whereas 5,5'-T-DAII adopts a slightly distorted DAII core by 6.7° and the dihedral angle between the DAII core and flanking thiophene is 35.6° . In comparison, both 6,6'-T-IID and 5,5'-T-IID are nonplanar; the flanked-thiophenes are twisted from the DAII core with the dihedral angles of around 35.5° , and IID cores are distorted by around 15.7° . The planarized DAII core relative to the IID core, especially as observed in 6,6'-T-DAII, would be associated with the electron-negative nitrogen on the DAII unit, and 6,6'-positionings of the flanking thiophenes contribute to releasing the steric hindrance to make the coplanar π -backbone. Obviously, the HOMO and LUMO levels of 6,6'-T-DAII and 5,5'-T-DAII are lower than those of the corresponding 6,6'-T-IID and 5,5'-T-IID, respectively, which means that the electron-withdrawing nitrogen can affect both the HOMO and LUMO levels. The HOMO and LUMO levels were estimated to be -7.526 eV and -1.664 eV for 6,6'-T-DAII and -7.804 eV and -1.700 eV for 5,5'-T-DAII, respectively. It is noteworthy that the 5,5'-substitution of 5,5'-T-DAII weakens the π -delocalization along the conjugated backbone at the central lactam part, which leads to a deeper HOMO of 5,5'-T-DAII than that of 6,6'-T-DAII. Meanwhile, LUMO of 5,5'-T-DAII are mainly concentrated on the DAII core. This reveals that the cross-conjugation of the 5,5'-connection is less effective for the expanding- π -conjugation as compared to the 6,6'-connection.



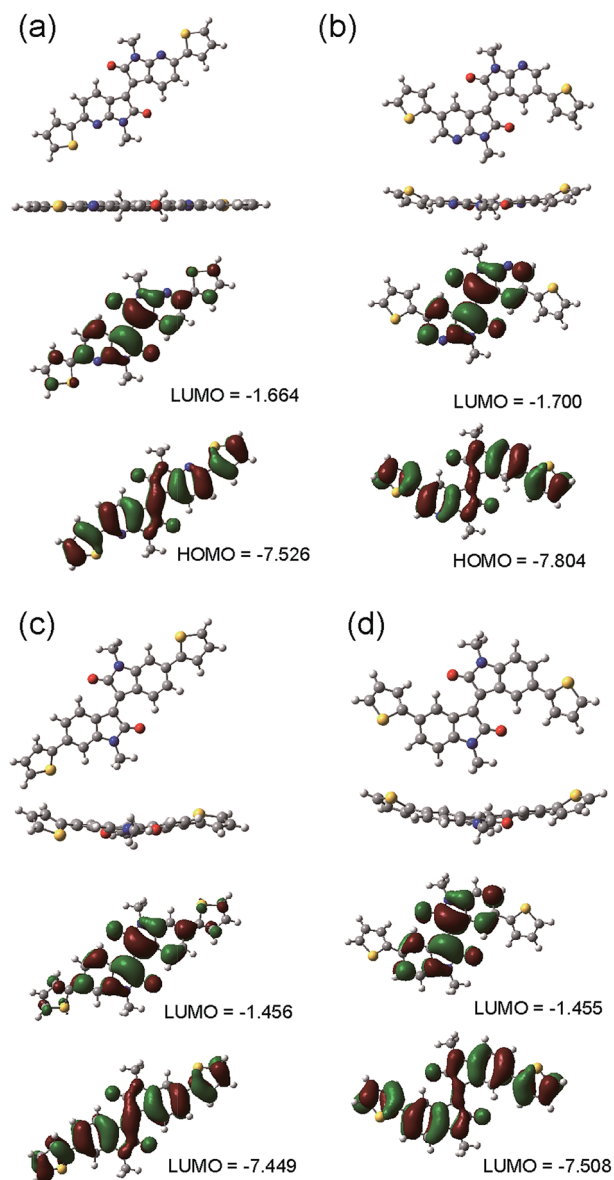


Fig. 2 Optimized structures and frontier molecular orbitals of (a) 6,6'-T-DAlI, (b) 5,5'-T-DAlI, (c) 6,6'-T-IID, (d) 5,5'-T-IID. Orbital energies are in eV.

Synthesis

The syntheses of the structural isomers 6,6'-T-DAlI and 5,5'-T-DAlI are outlined in Scheme 1. Hexyl chains are installed to improve the solubility for easy purification. Compound **1** was prepared following to a previous report.³⁷ For the preparation of **7a**, 6-brominated azaindole **1** was alkylated with hexyl bromide to afford **2**, which was treated with PBPB to obtain **3**,³⁸ and subsequent reduction with zinc afforded the 6-brominated-oxiindole **7a**. For the preparation of **7b**, the commercially-available azaindole **4** was first *N*-alkylated with hexyl bromide, then bromination with bromine afforded **6**,³⁹ which was subjected to selective reduction with zinc to provide the 6-brominated-oxindole **7b**. These brominated-oxiazaindoles **7a** and **7b** were readily converted to the corresponding isatins **8a**

and **8b**, respectively, as previously reported.⁴⁰ The condensation of the oxindoles **7a** and **7b** with the corresponding isatins **8a** and **8b** in refluxing acetic acid in the presence of a catalytic amount of HCl gave the two structural isomers **9a** and **9b**, respectively. Notably, **9a** and **9b** are key building blocks since π -elongated backbone could be readily achieved through various coupling reactions. The structural isomers 6,6'-T-DAlI and 5,5'-T-DAlI were obtained *via* the Stille coupling with tributylstannyl-thiophene.⁴¹

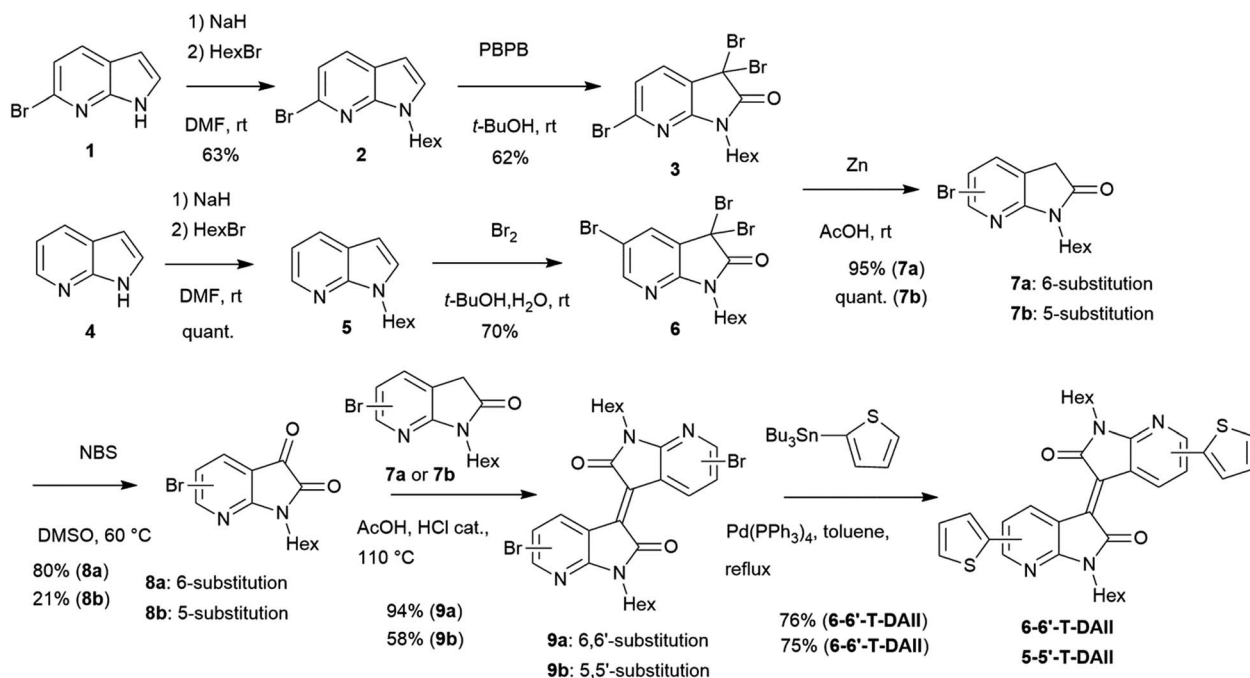
The newly synthesized DAlI derivatives were fully characterized by ¹H-NMR, ¹³C-NMR, mass spectroscopy, and elemental analysis. Thermogravimetric analysis (TGA) and differential scanning calorimetry (DSC) were performed on both molecules. The TGA profiles revealed that the two structural isomers 6,6'-T-DAlI and 5,5'-T-DAlI showed good thermal stabilities with the 5% weight loss at 350 °C for 6,6'-T-DAlI and at 332 °C for 5,5'-T-DAlI (Fig. S2†). The melting points and crystallization points determined from the DSC profiles are 275 °C and 263 °C for 6,6'-T-DAlI and 265 °C and 235 °C for 5,5'-T-DAlI, respectively (Fig. S3†).

Single crystal structures

Suitable crystals of 6,6'-T-DAlI, 5,5'-T-DAlI, and **9a** for the X-ray single crystal structure analysis were obtained by the slow diffusion of hexane into chloroform solutions of 6,6'-T-DAlI and 5,5'-T-DAlI and slow evaporation of the chloroform-hexane solution of **9a**. The crystallographic data are listed in Table S1.† The molecules of 6,6'-T-DAlI crystallize in the triclinic system with a space group *P*(1) while molecule **9a** and 5,5'-T-DAlI belong to the monoclinic system with the space group *P*₂₁/*n* for **9a** and *P*₂₁/*c* for 5,5'-T-DAlI, respectively. Thereby, in the crystals, the half molecule for 6,6'-T-DAlI, **9a**, and 5,5'-T-DAlI is crystallographically independent. As for the structure of 5,5'-T-DAlI, two molecular stacks are orthogonally aligned to each other along the *c* axis. Molecule **9a** has a flat π -framework and forms slipped one-dimensional stacks with the π - π stacking distance of 3.36 Å, demonstrating that this DAlI moiety is promising to obtain the planarized platform as predicted from the geometry optimization (Fig. 3).

It is instructive to compare the molecular and packing structures of the two structural isomers of 6,6'-T-DAlI and 5,5'-T-DAlI, which would have a strong influence on the carrier-transport. Both π -frameworks adopt a perfectly planar geometry. The planarity of 6,6'-T-DAlI well agrees with the optimized structures obtained from the calculations, while the planarized π -framework of 5,5'-T-DAlI is inconsistent with the estimated distorted structure. This observation is ascribable to the fact that the intermolecular ordering predominantly determines the molecular geometry. Molecules 6,6'-T-DAlI and 5,5'-T-DAlI pack into the slipped one-dimensional columnar structures with interplanar distances of 3.51 Å for 6,6'-T-DAlI and 3.32 Å for 5,5'-T-DAlI (Fig. 4). For the analysis of 6,6'-T-DAlI, we treated the terminal flanking thiophenes as a rotational disorder with S1 and C17 atoms, similarly to a previous report.⁴² Within the stack, the hexyl chain orientations are quite different; both hexyl chains of 6,6'-T-DAlI are oriented in plane whereas those





Scheme 1 Synthetic route of 6,6'-T-DAII and 5,5'-T-DAII.

of 5,5'-T-DAII extend out of the DAII plane. These findings indicate that the planar π -framework is more important than the hexyl chain conformation in order to realize the co-facial segregated molecular packing. In the structure of 6,6'-T-DAII, the disordered flanking thiophene are, presumably, arising from the removal of steric hindrance around the bond connecting the central DAII unit and peripheral thiophenes. These findings imply that the DAII unit itself has a strong tendency to interact with each other to make a columnar structure that forms a charge-transport path, in which no noticeable conformational lock that is important to the planarize molecular backbone is observed. The calculated transfer integrals⁴³ also indicate the one-dimensional transport of 6,6'-T-DAII and 5,5'-T-DAII, in which among the positionally disordered atoms

of 6,6'-T-DAII, the S1 and C17 atoms bearing a larger occupancy are employed in the calculation; the HOMO transfer integrals within the stacks are $t = 29$ meV for 6,6'-T-DAII and $t = 24$ meV for 5,5'-T-DAII, and LUMO transfer integrals are $t = 13$ meV for

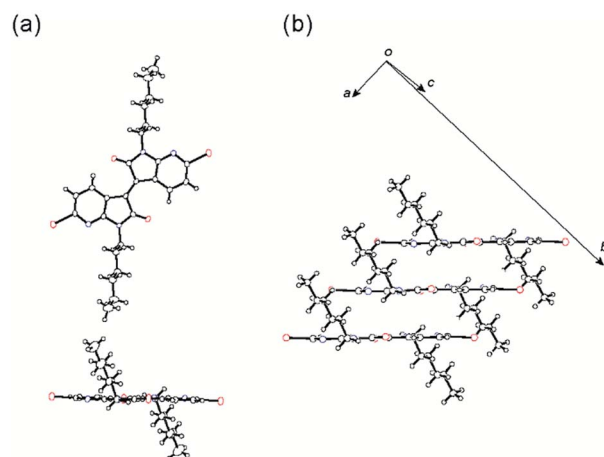


Fig. 3 (a) ORTEP plots at 50% ellipsoid probability and (b) molecular packing of 9a.

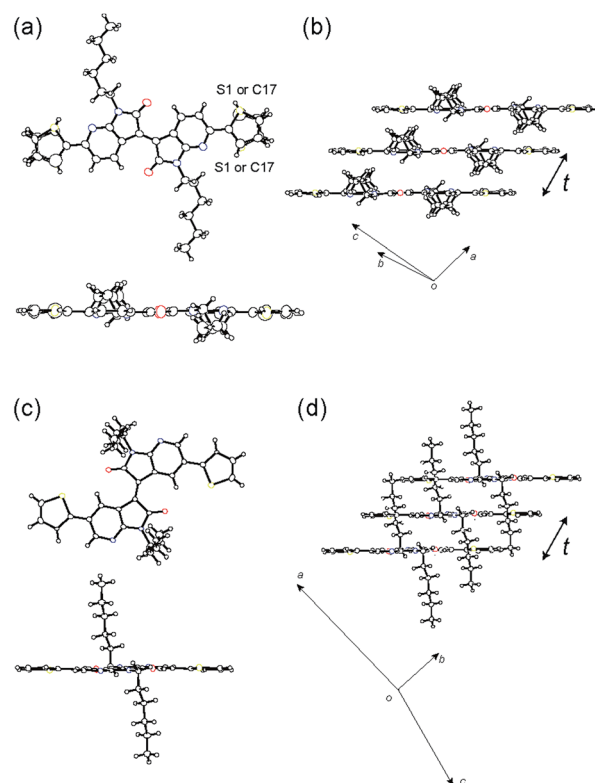


Fig. 4 ORTEP plots at 50% ellipsoid probability and molecular packings of 6,6'-T-DAII (a and b) and 5,5'-T-DAII (c and d).



Table 1 Summary of electrochemical and optical properties

| | E_{LUMO}^a (eV) | E_{HOMO}^a (eV) | $\lambda_{\text{max}}^{\text{sol}}(\epsilon_{\text{max}})^b$ (nm) ($\times 10^3 \text{ M}^{-1} \text{ cm}^{-1}$) | $\lambda_{\text{max}}^{\text{film}c}$ (nm) | $E_g^{\text{opt}d}$ (eV) |
|--------------------|--------------------------|--------------------------|--|--|--------------------------|
| 6,6'-T-DAII | −3.57 | −5.39 | 326 (3.69), 553 (2.67) | 333, 637 | 1.82 |
| 5,5'-T-DAII | −3.64 | −5.53 | 318 (4.96), 540 (0.26) | 320, 579 | 1.89 |

^a Estimated from the onset point of the reduction step and optical bandgaps. ^b Measured in CHCl_3 solutions. ^c Spin-coated film from CHCl_3 solutions. ^d Estimated from the solution absorption edge.

6,6'-T-DAII and $t = 29 \text{ meV}$ for **5,5'-T-DAII**, while the other interstack transfers are negligible.

Optical properties

The UV-Vis-NIR absorption spectra were recorded in the solutions and thin films of **6,6'-T-DAII** and **5,5'-T-DAII**, and the data are summarized in Table 1. In solutions, the molecules exhibited two absorption bands, in which the high-energy bands accompanying with shoulders are centered at 326 nm for **6,6'-T-DAII** and at 318 nm for **5,5'-T-DAII**, and the low-energy bands are centered at 553 nm for **6,6'-T-DAII** and 540 nm for **5,5'-T-DAII**. The optical band gaps of **6,6'-T-DAII** and **5,5'-T-DAII** were determined from the onset of absorption to be 1.82 and 1.89 eV, respectively. When going from solutions to thin films, all the absorption profiles are red-shifted and become more structural, which might be due to the intermolecular interactions in the solid state. It is noteworthy that the molar absorption coefficients in the low-energy band showed an especially clear dependence in the patterns of substitution; the absorption intensity of **5,5'-T-DAII** largely decreased in comparison to **6,6'-T-DAII**. In order to further examine the optical transitions of **6,6'-T-DAII** and **5,5'-T-DAII**, we carried out TD-DFT calculations at the $\omega\text{B97-XD/6-311++G(d,p)}$ level (Table 2). The low-energy band showing a remarkable difference between **6,6'-T-DAII** and **5,5'-T-DAII** is assigned to the HOMO \rightarrow LUMO transition with a mainly $\pi-\pi^*$ character. The oscillator strength for this transition was estimated to be 0.847 for **6,6'-T-DAII** and 0.148 for **5,5'-T-DAII**, well agreeing with the experimental observation. In spite of the large absorption difference, the optical bandgaps of **6,6'-T-DAII** and **5,5'-T-DAII** are almost similar at around

1.8 eV. Therefore, the substitution patterns in the DAII unit have a strong influence on the oscillator strength, but do not affect the optical bandgap as similarly reported for IID (Fig. 5).²⁴

Electrochemical properties

The electrochemical properties were examined by cyclic voltammetry (CV) in a standard three electrode electrochemical cell with an argon saturated dichloromethane solution containing 0.1 M Bu_4NPF_6 at room temperature using Ag/AgNO_3 as the reference electrode (Table 1). Both **6,6'-T-DAII** and **5,5'-T-DAII** exhibited irreversible reduction step (Fig. S4†). In the positive scan, no noticeable steps were observed, indicating the strong electron-accepting character of DAII unit. From the reduction onset potentials referenced to the Fc/Fc^+ couple, in which the absolute energy level is assumed to be 4.8 eV under vacuum,⁴⁴ the LUMO levels were estimated to be −3.57 eV for **6,6'-T-DAII** and −3.64 eV for **5,5'-T-DAII**. Based on the LUMO

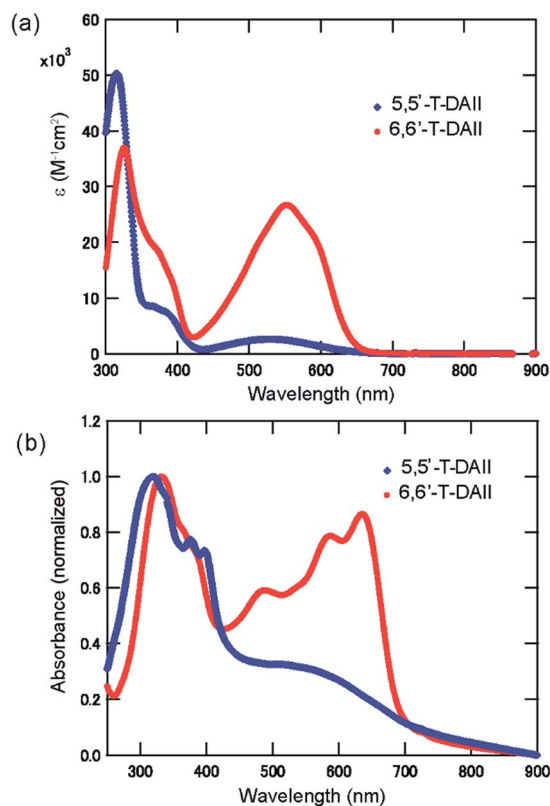


Fig. 5 UV-Vis absorption spectra of **6,6'-T-DAII** and **5,5'-T-DAII** in (a) CHCl_3 solutions and (b) thin films.

Table 2 DFT calculated optical transitions^a

| | λ_{max} (eV) | f | Main contributions to vertical transitions |
|--------------------|-----------------------------|-------|---|
| 6,6'-T-DAII | 2.73 | 0.847 | HOMO \rightarrow LUMO (45%) |
| | 4.13 | 0.856 | HOMO−2 \rightarrow LUMO (27%) |
| | 4.38 | 0.496 | HOMO \rightarrow LUMO+2 (25%) |
| 5,5'-T-DAII | 2.86 | 0.148 | HOMO \rightarrow LUMO (42%) |
| | 3.70 | 0.110 | HOMO−7 \rightarrow LUMO (21%), HOMO−2 \rightarrow LUMO (17%) |
| | 4.03 | 0.380 | HOMO−2 \rightarrow LUMO (14%), HOMO−2 \rightarrow LUMO (20%) |
| | 4.50 | 1.273 | HOMO−1 \rightarrow LUMO+2 (16%), HOMO−9 \rightarrow LUMO (25%) |

^a The transitions with oscillator strengths over 0.1 are listed.



Table 3 FET properties^a

| Compound | p-type | | | | n-type | | | |
|-------------|---|---|---------------------|--------------------------------|---|---|---------------------|--------------------------------|
| | μ_{ave} ($\text{cm}^2 \text{V}^{-1} \text{cm}^{-1}$) | μ_{max} ($\text{cm}^2 \text{V}^{-1} \text{cm}^{-1}$) | V_{th} (V) | $I_{\text{on}}/I_{\text{off}}$ | μ_{ave} ($\text{cm}^2 \text{V}^{-1} \text{cm}^{-1}$) | μ_{max} ($\text{cm}^2 \text{V}^{-1} \text{cm}^{-1}$) | V_{th} (V) | $I_{\text{on}}/I_{\text{off}}$ |
| 6,6'-T-DAlI | 1.0×10^{-3} | 2.1×10^{-3} | -75 | 10^4 | 1.5×10^{-3} | 2.0×10^{-3} | 31 | 10^4 |
| 5,5'-T-DAlI | 1.7×10^{-3} | 2.6×10^{-3} | -120 | 10^4 | 3.8×10^{-3} | 8.6×10^{-3} | 55 | 10^4 |

^a Measurements were carried out under vacuum. Average mobilities of at least 12 devices are listed.

levels and optical bandgaps, the HOMO levels were estimated to be -5.39 eV for 6,6'-T-DAlI and -5.53 eV for 5,5'-T-DAlI. The similar LUMO level and deeper HOMO level of 5,5'-T-DAlI relative to 6,6'-T-DAlI are basically consistent with the trend of the DFT calculations.

Charge-transport properties

The charge-transporting properties of 6,6'-T-DAlI and 5,5'-T-DAlI were evaluated with a bottom-gate and top contact configuration in FET devices. The semiconducting layer was thermally deposited on a tetratetracontane (TTC) modified SiO_2/Si substrate, and Au contacts were patterned by thermal evaporation. The TTC layer is known to form a superior defect-free interface with active layers to observe the intrinsic FET characteristics of the molecules.⁴⁵ The measurement was performed in a vacuum to eliminate the influence of the ambient condition. The FET data are summarized in Table 3, and typical transfer curves are shown in Fig. 6. The devices made of 6,6'-T-DAlI and 5,5'-T-DAlI showed an ambipolar charge-transport, and their hole and electron mobilities are on the same order of $10^{-3} \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$. The electron mobility is slightly improved relative to the hole mobility, suggesting an n-type dominant

character due to the electron-deficient DAlI core. Most importantly, the devices made of 6,6'-T-DAlI and 5,5'-T-DAlI exhibited a comparable carrier-transport performance irrespective of the thiophene-flanked positions, suggesting that chemical modifications at both the 5- and 6-connections of the DAlI core contribute to the carrier-transport. Of particular emphasis is that the 5,5'-substituted 5,5'-T-DAlI obviously improves the carrier mobilities, especially concerning electron-transport, as compared to the 6,6'-substituted 6,6'-T-DAlI. When considering the molecular packing in the crystal structures, this is ascribable to the smaller interplanar distance of 5,5'-T-DAlI without the absence of any positional disorder of the flanked-thiophenes, thus realizing a more compact molecular packing within the stack. In general, the connection at the 5-position of the DAlI core, namely, cross-conjugation, is considered to prevent lateral π -conjugation, implying negative impressions for making co-facial molecular π -stacks. However, we should state that the expanding backbone at the 5-position on the DAlI core affords rather active influences on the charge-transport (Fig. 7).

Thin film microstructure and morphologies

The X-ray diffraction (XRD) patterns and atomic force microscopy (AFM) images of the thin films of 6,6'-T-DAlI and

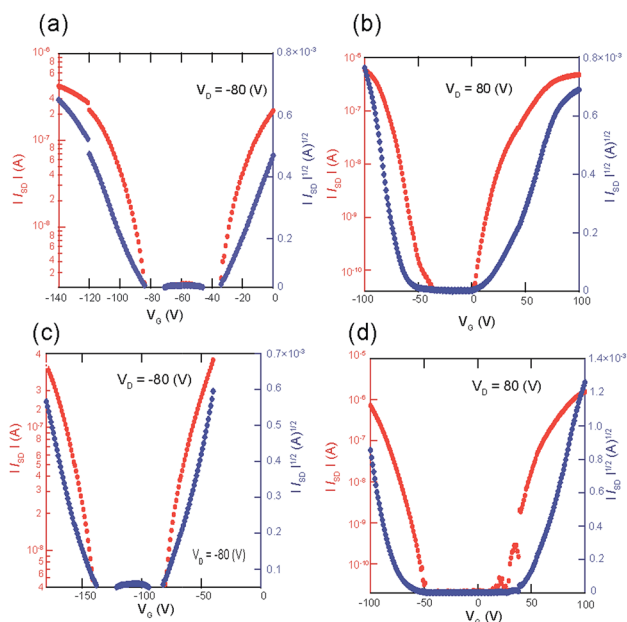


Fig. 6 The typical transfer curves of (a) p-channel and (b) n-channel scans for 6,6'-T-DAlI and (c) p-channel and (d) n-channel scans for 5,5'-T-DAlI.

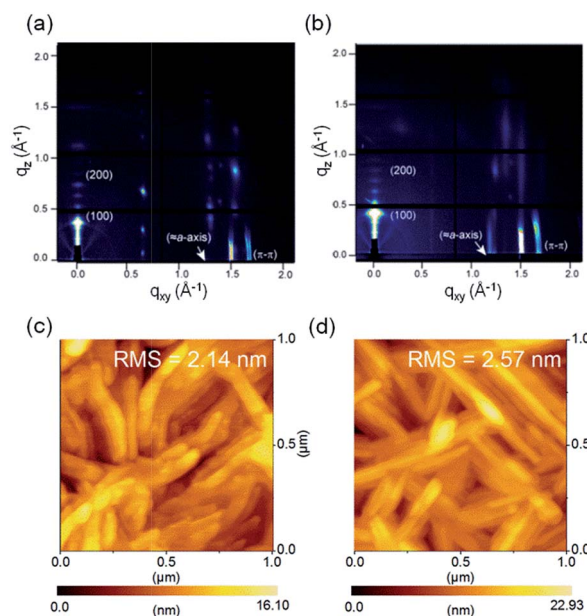


Fig. 7 GIXD patterns and AFM height images of (a) and (c) for 6,6'-T-DAlI and (b) and (d) for 5,5'-T-DAlI.



5,5'-T-DAII were employed to examine the thin-film microstructures and surface morphologies. Thin films of 6,6'-T-DAII and 5,5'-T-DAII displayed sharp and intense primary peaks in the out-of-plane direction at the q_z of 0.37 for 6,6'-T-DAII and at 0.41 for 5,5'-T-DAII, suggesting the presence of a periodic packing motif normal to the substrate, and the corresponding d -spacings are 17.2 Å for 6,6'-T-DAII and 15.2 Å for 5,5'-T-DAII. In the in-plane-direction, 6,6'-T-DAII and 5,5'-T-DAII displayed peaks corresponding to the π - π stacking distances of 3.75 Å as well. Additionally, the peaks of 6,6'-T-DAII and 5,5'-T-DAII centered at the q^{-1} of 1.25 corresponding to ≈ 5.0 Å, which is approximately consistent with the lengths of the crystallographic a axis in the single crystal structures of 6,6'-T-DAII and 5,5'-T-DAII. Although it is hard to determine the exact molecular orientation, when considering the molecular lengths of 6,6'-T-DAII and 5,5'-T-DAII estimated from X-ray single crystal structure analyses, these observations indicate that uniformly stacked columnar structures are organized parallel to the substrate, in which the molecular long axes of 6,6'-T-DAII and 5,5'-T-DAII are tilted by $\approx 20^\circ$ normal to the substrate. These parallel molecular orders of the carrier-transporting plane are preferable for carrier transport in FETs. In the AFM height images, both thin films were composed of almost the same interconnected fibril-like grains. These thin-film microstructures and surface morphologies are well rationalized with their comparable FET performances. It is interesting that the structural isomers 6,6'-T-DAII and 5,5'-T-DAII, which possess different platforms and electronic structures originating from the substitution patterns, exhibited the same order of magnitude of carrier mobilities, and 5,5'-T-DAII displayed further enhanced carrier mobilities. These results reveal that the present DAII core does not reduce the charge-transport properties irrespective of the 5- or 6-substitution patterns.

Conclusions

In conclusion, a novel electron-deficient building unit, DAII, was designed and synthesized. The dibrominated-DAIIs are useful coupling partners with a synthetic diversity for preparing semiconducting materials. The optical, electrochemical, and carrier-transport properties were examined by specifically on the impact of the connection patterns on the structure-property relationship. The two structural isomers of 6,6'-T-DAII and 5,5'-T-DAII exhibited an ambipolar semiconductor performance with hole and electron carrier mobilities of $10^{-3} \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$. Of particular interest is that the 5,5'-substitution on the DAII core improved carrier-transport characteristics in comparison to the 6,6'-substitution. This finding reveals that the molecular packing coming from the connection pattern is an important factor to govern the carrier-transport even if the cross-conjugated FMOs exist on the backbone, which is generally considered to result in poor intermolecular couplings. Our preliminary results demonstrated that the DAII unit is a promising n-type building block and provides an option of connection patterns for creating small-molecule and polymeric semiconductors. The exploration of new organic semiconductors composed of the DAII unit is currently under way.

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